SECTION I LIST OF MANUFACTURERS' QUALIFIED CAPABILITIES FOR EACH TECHNOLOGY

MANUFACTURER INFORMATION: FTG Circuits, Inc. - Chatsworth

20750 Marilla Street, Chatsworth,, CA, 91311 US

Phone: 818-407-4024

Fax: 818-407-4034
EMail: info@ftgcorp.com

CAGE Code: 30803

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-19-033705

Composition: S - Homogenous thermosetting base material printed boards Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 20
Max. Board Thickness: .165"

Min. Hole Size: .016" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 8.9:1 Through-Hole Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au Additional Fab Capabilities: Blind Vias, Foil Lamination, Metal Core, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-19-033708

Composition: M - Mixed based material printed boards, S - Homogenous thermosetting base material printed boards

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant; GI: Glass Base, Woven, Polyimide Resin, Heat Resistant

Flex Base Material: Copper Clad Adhesiveless Polyimide

Max. Panel Size: 18" x 24" Max. Number of Layers: 20 Max. Board Thickness: .18"

Min. Hole Size: .0197" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 10:1 Through-Hole

Min. Conductor Width/Space: .0035"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

Controlled Impedance: Differential, Single-Ended Flex Usage: Use A (Flex During Installation)

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/3, MIL-PRF-31032/4

Qualification Letters: VQE-19-033709

Composition: M - Mixed based material printed boards

Rigid Base Material: GF: Woven E-Glass, Epoxy Resin, Flame Resistant Flex Base Material: Copper Clad Polyimide with Acrylic Adhesive

Max. Panel Size: 18" x 24"
Max. Number of Layers: 18
Max. Board Thickness: .165"

Min. Hole Size: .0256" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 6.5:1 Through-Hole
Min. Conductor Width/Space: .007"/.005"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate

Finish System: ENIG, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

Flex Usage: Use A (Flex During Installation)

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CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-19-033706

Composition: S - Homogenous thermosetting base material printed boards Rigid Base Material: Gl: Glass Base, Woven, Polyimide Resin, Heat Resistant

Max. Panel Size: 18" x 24"
Max. Number of Layers: 32
Max. Board Thickness: .201"

Min. Hole Size: .005" Laser Ablated Plated Hole Size Before Plating, .01" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 11.3:1 Through-Hole, 1:1 Microvia Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au Additional Fab Capabilities: Blind Vias, Buried Vias, Foil Lamination, Metal Core, Sequential Lamination

Controlled Impedance: Differential, Single-Ended

CAPABILITIES BY TECHNOLOGY/ASSOCIATED SPECIFICATION

Specification: MIL-PRF-31032/1, MIL-PRF-31032/2

Qualification Letters: VQE-19-033707

Composition: S - Homogenous thermosetting base material printed boards Rigid Base Material: BI: Aramid Fabric, Nonwoven, Polyimide Resin

Max. Panel Size: 18" x 24" Max. Number of Layers: 16 Max. Board Thickness: .095"

Min. Hole Size: .0079" Drilled Plated-Through Hole Before Plating

Aspect Ratio: 12:1 Through-Hole
Min. Conductor Width/Space: .004"/.004"

Hole Preparation: Plasma Desmear, Plasma Etchback Hole Wall Conductive Coating: Electroless Copper

Copper Plating: Direct Current Plate Hole Fill/Via Plug: Non-Conductive Solder Resist: Liquid Photoimageable

Finish System: ENIG, Electrolytic Ni / Soft Au, HASL, Hot Oil Reflow of Plated Sn/Pb, Ni/Pd/Au

Additional Fab Capabilities: Foil Lamination
Controlled Impedance: Differential, Single-Ended